

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	183	(HF or hydrofluoric) same ("hydrogen peroxide" or "H.sub.2O.sub.2") same (edge or peripheral)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 13:55
L2	4366	(HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2") and (edge or peripheral)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 14:21
L3	3275	(HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2") and (edge or peripheral) and etch\$4	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 13:56
L4	2214	(HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2") and (edge or peripheral) and etch\$4 and wafer	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:05
L5	1386	(edge or peripheral) and etch\$4 and (back adj wafer)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 14:46
L6	12957	(HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2")	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 14:21
L7	59	5 and 6	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 14:22
L8	317	5 and (HF or hydrofluoric)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 14:23

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L9	71096	(edge or peripheral) and etch\$4 and (wafer)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 14:47
L10	11593	(edge or peripheral) same etch\$4 same (wafer)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 15:05
L11	907	(edge or peripheral) same etch\$4 same (wafer) same (HF or hydrofluoric)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 15:04
L12	14292	(edge or peripheral) and etch\$4 and (wafer) and (HF or hydrofluoric)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 15:04
L13	2822	10 and (HF or hydrofluoric)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 15:05
L14	2545	13 and semiconductor	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:02
L15	2	"6331479".pn.	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:02
L16	185	(HF or hydrofluoric) same ("hydrogen peroxide" or "H.sub.2O.sub.2") same (edge or peripheral or perimeter)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:07

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L17	4438	(HF or hydrofluoric) and ("hydrogen peroxide" or "H.sub.2O.sub.2") and (edge or peripheral or perimeter)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:14
L18	2857	17 and etch\$4 and semiconductor	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:15
L19	46160	(HF or hydrofluoric) and (edge or peripheral or perimeter)	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:14
L20	25662	(HF or hydrofluoric) and (edge or peripheral or perimeter) and etch\$4	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:15
L21	3522	(HF or hydrofluoric) same (edge or peripheral or perimeter) same etch\$4	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:33
L22	2764	21 and semiconductor	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:15
L23	1126	(HF or hydrofluoric) same (edge or peripheral or perimeter) same wafer	US-PGPUB; USPAT; USOCR; JPO; DERWENT; IBM_TDB	OR	ON	2006/07/19 16:33